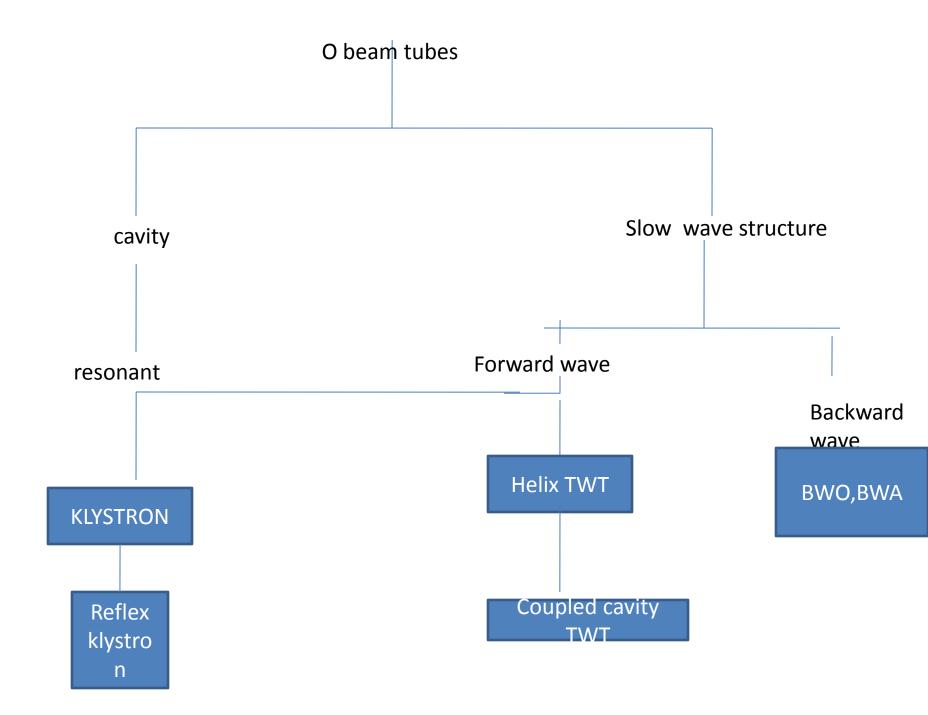
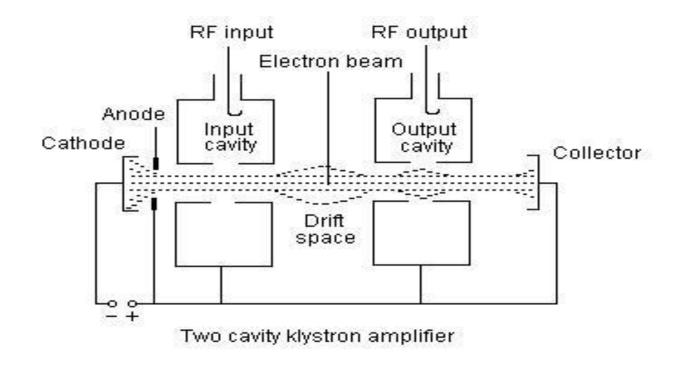
• LINEAR BEAM TUBES (o) type



TWO CAVITY KLYSTRON

- Vacuum tube either as generator or amplifier
- RUSSEL H VARIAN



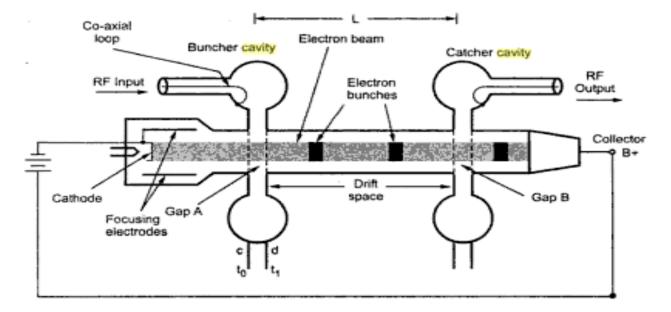
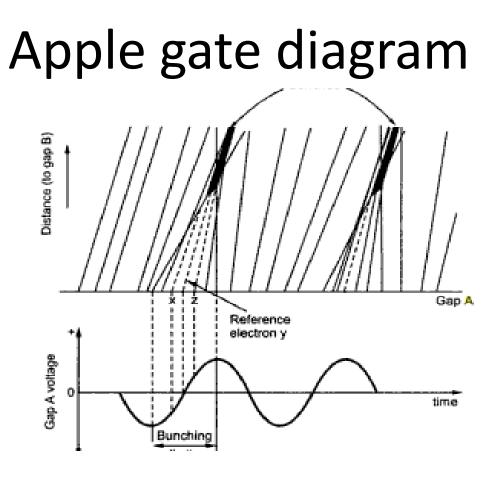
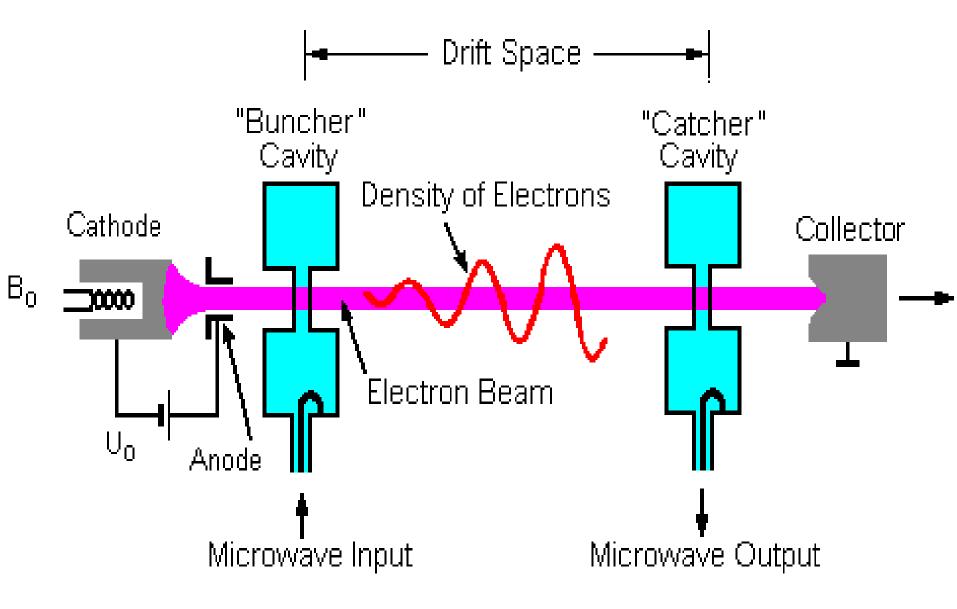


Fig. 4.4.1 Klystron amplifier schematic diagram



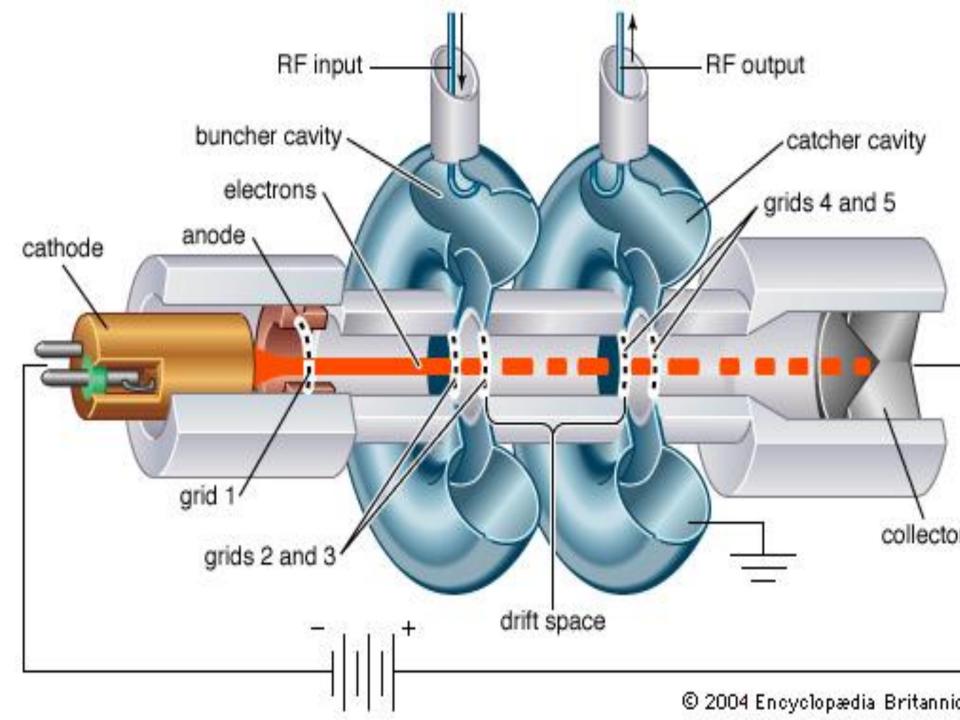
Two Cavity Klystron Amplifier



Principle

- Velocity modulated tube
- High velocity electron beam is generated by an electron gun and sent down along a gas tube through an input cavity (BUNCHER), drift space (FIELD FREE) and an output cavity (CATCHER) to a collector electrode anode.
- The anode is kept positive to receive the electrons, while the output is taken from the tube via resonant cavities with the aid of coupling loops

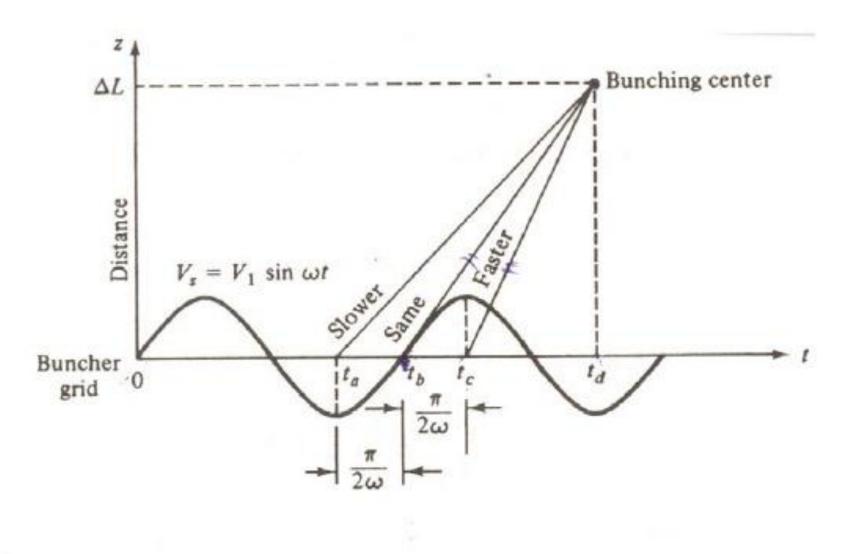
• Two grids of the buncher cavity are separated by a small gap A while the two grids of the catcher cavity are separated by a small gap B.



OPERATION

- The input buncher cavity is exited by the RF signal, (the signal to be amplified) which will produce an alternating voltage of signal frequency across the gap A.
- This voltage generated at the gap A is responsible to produce bunching of electrons or velocity modulation of the electron beam.

Applegate Diagram



Performance Characteristics

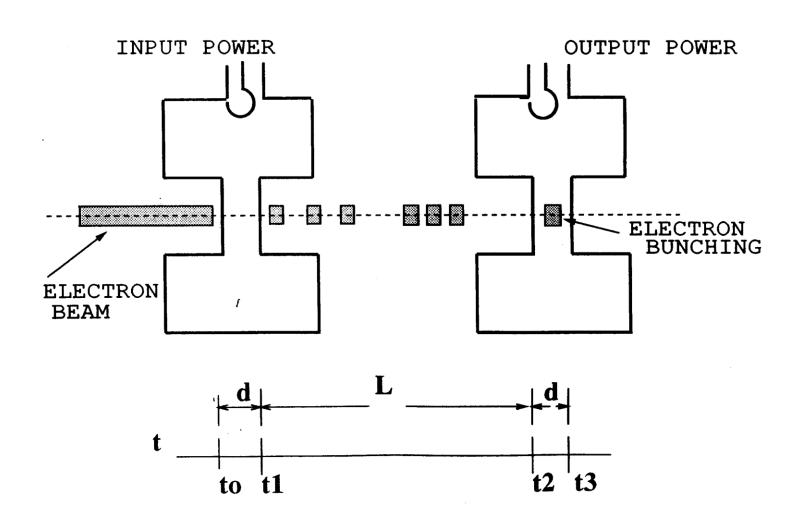
- Frequency 250Mhz-100 GHz
- Power -10kw -500 Kw
- Power gain 15 db-70 db
- Bandwidth limited 10-60 Mhzfixed application
- Noise figure -15-20 db
- Efficiency -58%

Application

- 1) As power o/p tubes
- In UHF TV transmitter
- In troposphere scatter Transmitter
- Satellite Communication Ground station
- Radar transmitter
- 2) As power oscillator (5-50 Ghz) is used as Klystron amplifier

KLYSTRON

SIMPLIFIED SCHEMATIC



Mathematical analysis

$$v_{0} = \sqrt{\frac{2eV_{0}}{m}} = 0.593 * 10^{6} \sqrt{v_{0}} m/s$$

$$V_{s} = V_{1} \sin wt_{1}$$

$$\frac{1}{2} m v_{1}^{2} = e(V_{o} + V_{1} Sinwt_{1})$$

$$v_{1} = \sqrt{\frac{2e(V_{o} + V_{1} Sinwt_{1})}{m}}$$

$$v_{1} = v_{0} \left(1 + \frac{V_{1}}{V_{0}} \sin wt_{1}\right)^{1/2}$$

$$v_{1} = v_{0} \left(1 + \frac{V_{1}}{2V_{0}} \sin wt_{1}\right)$$

$$wt_{1} = wt_{o} + \frac{\theta_{g}}{2}$$

 θ_{g} is the phase angle of RF input voltage

$$wt_1 = wt_o + \frac{\theta_g}{2}$$

 θ_g is the phase angle of RF input voltage $\theta_g = \omega t = \omega (t_1 - t_0) = \frac{\omega d}{v_0}$

Bunching process of Electron Beam

$$v_{1(\max)} = v_0 \left(1 + \frac{V_1}{2V_0} \right) \text{ at } \pi/2$$
$$v_{1(\min)} = v_0 \left(1 - \frac{V_1}{2V_0} \right) \text{ at } - \pi/2$$

 $L_1 = v_0 (t_1 - t_0)$

Bunching process of Electron Beam $L(t_{-\pi/2}) = v_{\min}(t_1 - t_{-\pi/2})$ $L(t_{\pi/2}) = v_{\max}(t_1 - t_{+\pi/2})$ $t_{-\pi/2} = (t_0 - \pi/2\omega)$ $t_{\pi/2} = (t_0 + \pi/2\omega)$ $L_1 \text{ at } t_{-\lambda/2} = vo\left(1 + \frac{V_1}{2V_0}\right)(t_1 - t_0 + \pi/2\omega)$ $L_1 \text{ at } t_{+\lambda/2} = vo\left(1 + \frac{V_1}{2V_0}\right)(t_1 - t_0 - \pi/2\omega)$

$$\therefore L_{1} = v_{0}(t_{1} - t_{0}) + v_{o} \left[\frac{\pi}{2\omega} - \frac{V_{1}}{2V_{0}} (t_{1} - t_{0}) - \frac{V_{1}}{2V_{0}} \pi / 2\omega \right]$$

$$\left[\frac{\pi}{2\omega} - \frac{V_{1}}{2V_{0}} (t_{1} - t_{0}) - \frac{V_{1}}{2V_{0}} \pi / 2\omega \right] = 0$$

$$- (t_{1} - t_{0}) = \frac{\pi}{2\omega} \left[\frac{V_{1}}{2V_{0}} - 1 \right] \frac{2V_{0}}{V_{1}}$$

$$= \frac{\pi}{2\omega} - \frac{\pi}{\omega} \frac{V_{0}}{V_{1}}$$

$$t_{1} - t_{0} \approx \frac{\pi}{\omega} \frac{V_{0}}{V_{1}}$$

$$L_{1} = v_{0} \left(\frac{\pi}{\omega} \frac{V_{0}}{V_{1}} \right)$$